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Substitute for Form 1449 A & B/PTO	Application Number	10/735,769		
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	First Named Inventor	Koichi KAWAMURA		
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Examiner Initials*	Cite No.1	Document Number		Publication Date	
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Examiner Initials*	Cite No.1	Foreign Patent Document			Publication Date	Name of Patentee or	T
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Examiner Initials*	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation
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<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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